

SEP 10 2007

Docket No.: 020732-97.668 (7493)
Appl. No. 10/792,038

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:		Docket No.:	020732-97.668 (7493)
Applicants:	RATH, Melissa K., et al.	Conf. No.:	4823
Application No.:	10/792,038	Art Unit:	1752
Date Filed:	March 3, 2004	Examiner:	LE, Hoa Van
Title:	COMPOSITION AND PROCESS FOR POST-ETCH REMOVAL OF PHOTORESIST AND/OR SACRIFICIAL ANTI-REFLECTIVE MATERIAL DEPOSITED ON A SUBSTRATE	Customer No.:	24239

FACSIMILE TRANSMISSION CERTIFICATE


Attn: Examiner Hoa Van Le

Fax No. (571) 273-8300

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Number of Pages (including cover)


Tristan A. Fuierer

September 10, 2007

Date _____

**AMENDMENT RESPONDING TO JULY 9, 2007 OFFICE ACTION AND SUPPLEMENTAL
INFORMATION DISCLOSURE STATEMENT IN UNITED STATES PATENT
APPLICATION NO. 10/792,038**

**Mail Stop AF
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450**

Sir:

This responds to the July 9, 2007 Office Action in the above-identified application.

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Please amend the claims, as set out in the following **Section I (the Claims)**.

Remarks addressing the substance of the July 9, 2007 Office Action are set out in the **Section II (Remarks)** hereof.

A Supplemental Information Disclosure Statement and Certification Statement are enclosed and concurrently submitted herewith.